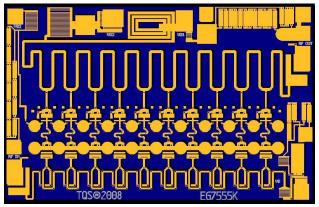
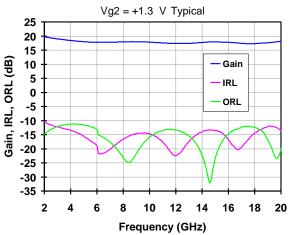


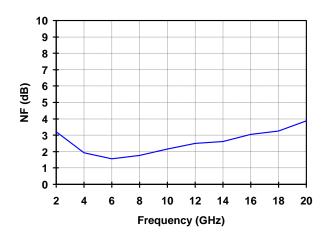
2 - 20 GHz Low Noise Amplifier with AGC



Measured Performance

Bias conditions: Vd = 5 V, Id = 100 mA, Vg1 = -0.55 V,





Key Features

Frequency Range: 2 - 20 GHz

Midband NF: 2.5 dB

Gain: 17.5 dB

>30 dB adjustable gain with Vg2

TOI: 29 dBm Typical

22 dBm Nominal Psat, 20 dBm Nominal P1dB

ESD Protection circuitry on Vd, Vg1, and Vg2

 Bias: Vd = 5 V, Id = 100 mA, Vg1 = -0.55 V, Vg2 = +1.3 V, Typical

Technology: 3MI 0.15 um Power pHEMT

Chip Dimensions: 2.090 x 1.350 x 0.100 mm

Primary Applications

Wideband Gain Block / LNA

X-Ku Point to Point Radio

Electronic Warfare Applications

Product Description

The TriQuint TGA2526 is a compact LNA Gain Block MMIC with adjustable gain control (AGC). The LNA operates from 2-20 GHz and is designed using TriQuint's proven standard 0.15 um Power pHEMT production process.

The TGA2526 provides a nominal 20 dBm of output power at 1 dB gain compression with a small signal gain of 17.5 dB. Greater than 30 dB adjustable gain can be achieved using the Vg2 pin. Typical noise figure is 2.5 dB at 12 GHz. Special circuitry on Vd, Vg1 and Vg2 pins provides ESD protection.

The TGA2526 is suitable for a variety of wideband systems such as point to point radios, radar warning receivers and electronic counter measures.

The TGA2526 is 100% DC and RF tested on-wafer to ensure performance compliance. The TGA2526 has a protective surface passivation layer providing environmental robustness.

Lead-Free & RoHS compliant.

Evaluation Boards are available upon request.

Datasheet subject to change without notice.



Table I Absolute Maximum Ratings <u>1</u>/

	<u> </u>				
Symbol	Parameter	Value	Notes		
Vd-Vg	Drain to Gate Voltage	9 V			
Vd	Drain Voltage	7 V	<u>2</u> /		
Vg1	Gate # 1 Voltage Range	-2 to 0 V			
Vg2	Gate # 2 Voltage Range	-2 to +3 V			
ld	Drain Current	144 mA	<u>2</u> /		
lg1	Gate # 1 Current Range	-20 to 14 mA			
lg2	Gate # 2 Current Range	-20 to 14 mA			
Pin	Input Continuous Wave Power	22 dBm	<u>2</u> /		
Tchannel	Channel Temperature	200 °C			

- These ratings represent the maximum operable values for this device. Stresses beyond those listed under "Absolute Maximum Ratings" may cause permanent damage to the device and / or affect device lifetime. These are stress ratings only, and functional operation of the device at these conditions is not implied.
- 2/ Combinations of supply voltage, supply current, input power, and output power shall not exceed the maximum power dissipation listed in Table IV.
- 3/ ESD protection diodes on Vd, Vg1 and Vg2 will conduct current for voltages approaching turn-on voltages. Diode turn-on voltage levels will decrease with decreasing temperature.

Table II Recommended Operating Conditions

Symbol	Parameter <u>1</u> /	Value
Vd	Drain Voltage	5 V
ld	Drain Current	100 mA
Id_Drive	Drain Current under RF Drive	144 mA
Vg1	Gate # 1 Voltage	-0.55 V
Vg2	Gate # 2 Voltage	1.3 V

1/ See assembly diagram for bias instructions.



Table III RF Characterization Table

Bias: Vd = 5 V, Id = 100 mA, Vg1 = -0.55 V, Vg2 = +1.3 V, typical

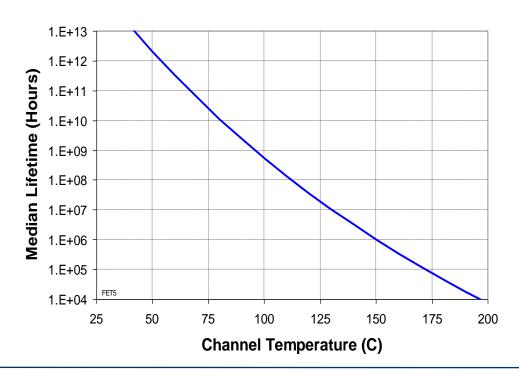
SYMBOL	PARAMETER	TEST CONDITIONS	MIN	NOMINAL	MAX	UNITS
Gain	Small Signal Gain	f = 2 – 18 GHz	16	17.5	-	dB
		f = 18 – 20 GHz	15	16		
IRL	Input Return Loss	f = 2 – 4 GHz	10	11	-	dB
		f = 4 – 20 GHz	12	13	-	
ORL	Output Return Loss	f = 2 – 6 GHz	10	11	-	dB
		f = 6 – 20 GHz	10	13	-	
Psat	Saturated Output	f = 2 – 18 GHz	-	22	-	dBm
	Power	f = 18 – 20 GHz	-	20		
P1dB	Output Power @	f = 2 – 16 GHz	17	20	-	dBm
	1dB Compression	f = 16 – 20 GHz	15	17	-	
TOI	Output TOI	f = 2 – 12 GHz	-	30	-	dBm
		f = 12 – 20 GHz	-	26	-	
NF	Noise Figure	f = 2 – 4 GHz	-	3	3.5	dB
		f = 4 – 14 GHz	-	2.5	3	
		f = 14 – 20 GHz	-	3.5	4.5	



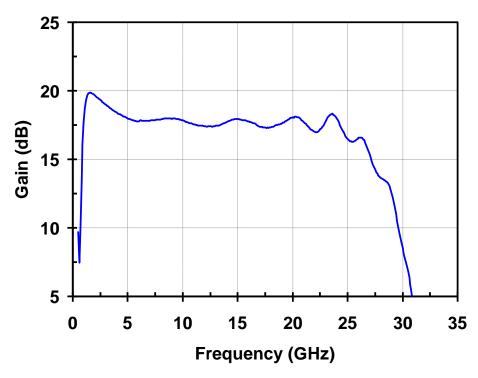
Table IV
Power Dissipation and Thermal Properties

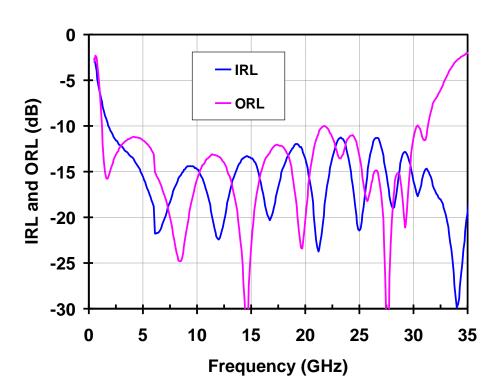
Parameter	Test Conditions	Value
Maximum Power Dissipation	Tbaseplate = 70 °C	Pd = 1.01 W Tchannel = 113 °C Tm = 9.1 E+7 Hrs
Thermal Resistance, θjc	Vd = 5 V Id = 100 mA Pd = 0.5 W	θjc = 42.2 °C/W Tchannel = 91 °C Tm = 2.0 E+9 Hrs
Thermal Resistance, θjc Under RF Drive	Vd = 5 V Id = 144 mA Pout = 22 dBm Pd = 0.562 W	θjc = 42.2 °C/W Tchannel = 94 °C Tm = 1.3 E+9 Hrs
Mounting Temperature	30 Seconds	320 °C
Storage Temperature		-65 to 150 °C

Median Lifetime vs Channel Temperature

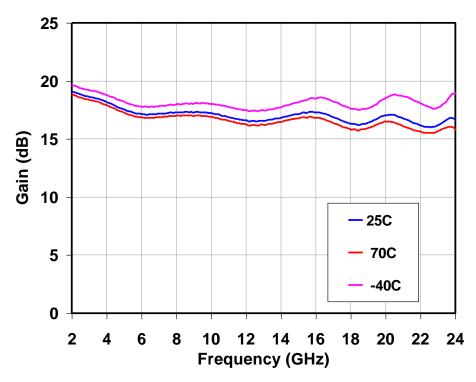


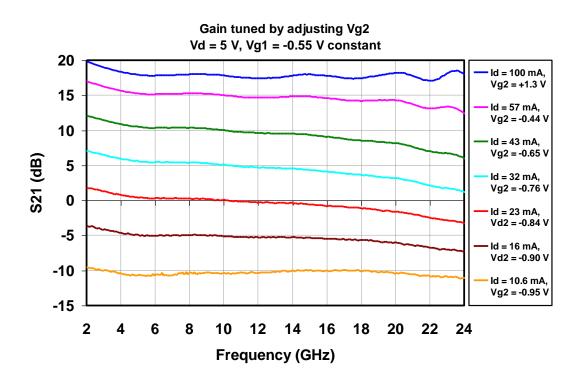




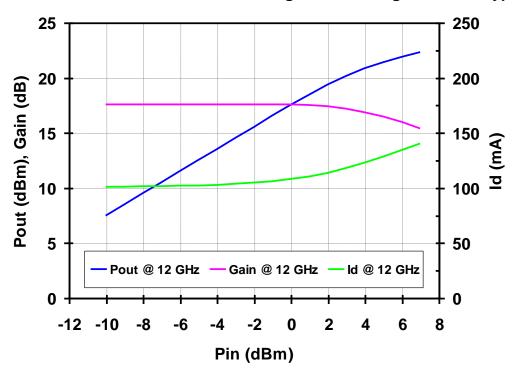


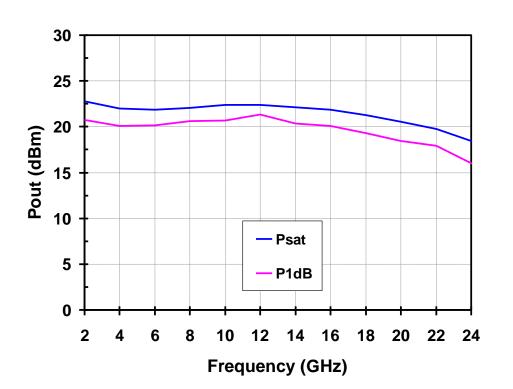




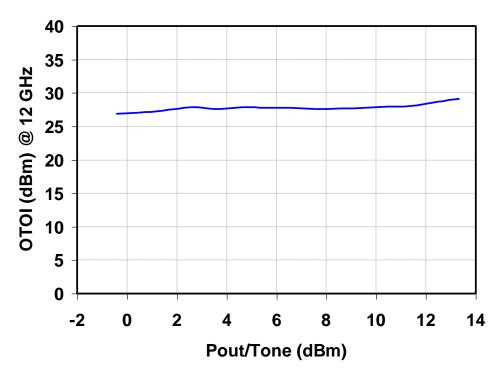


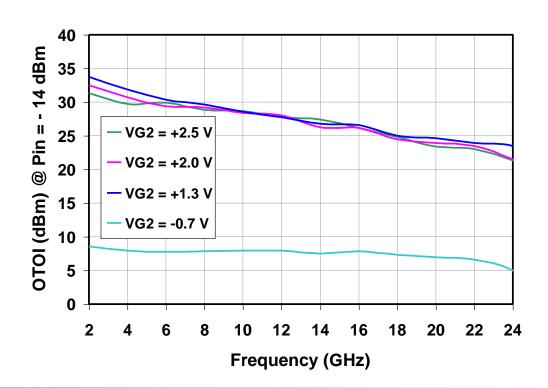




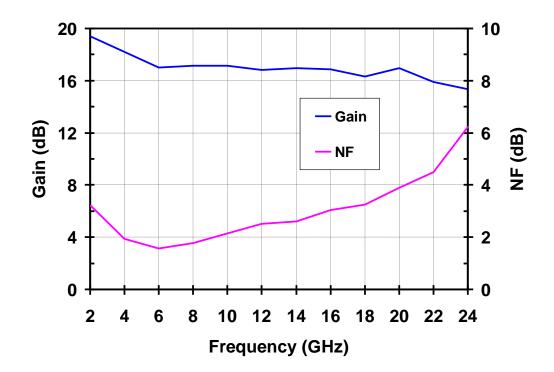






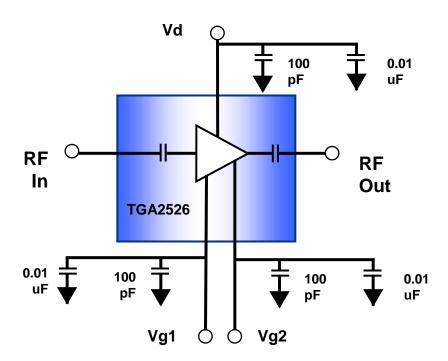








Electrical Schematic

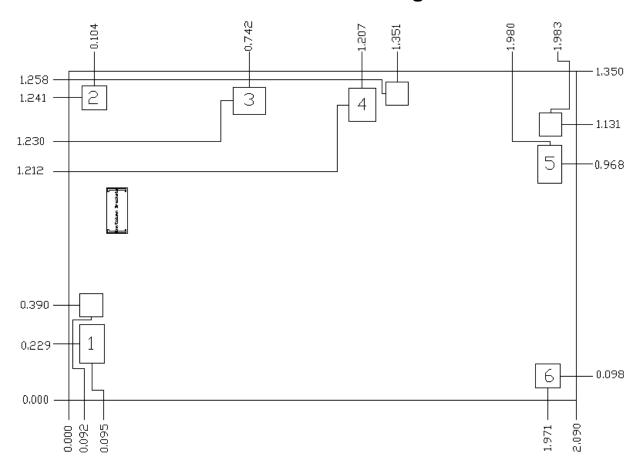


Bias Procedures

Bias-up Procedure	Bias-down Procedure
Vg1 set to -1.5 V	Set Vg2 to +1.3 V
Vd set to +5 V	Turn off RF supply
Vg2 set to +1.3 V	Reduce Vg1 to -1.5 V. Ensure Id ~ 0 mA
Adjust Vg1 more positive until Id is 100 mA. This will be \sim Vg1 = -0.55 V	Turn Vg2 to 0 V
Apply RF signal to input	Turn Vd to 0 V
Adjust Vg2 to obtain desired gain.	Turn Vg1 to 0 V



Mechanical Drawing



Units: millimeters Thickness: 0.10

Die x,y size tolerance: +/ - 0.050

Chip edge to bond pad dimensions are shown to center of pad

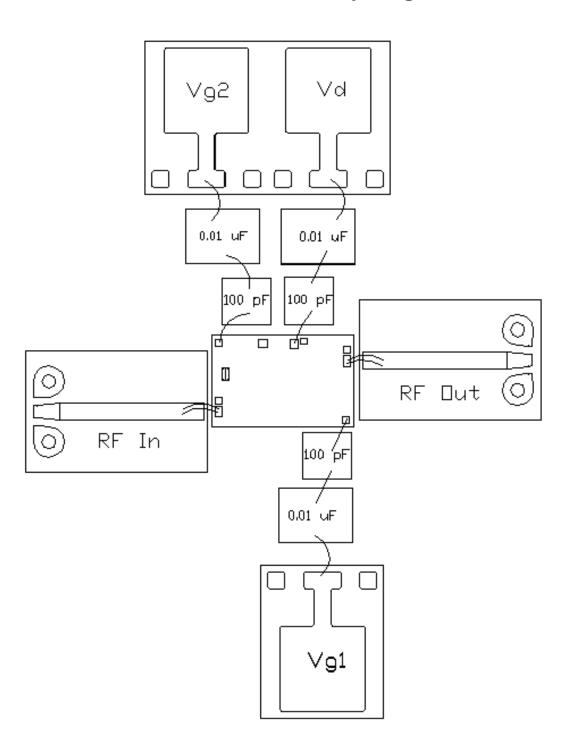
Ground is backside of die

Bond Pad # 1	RF In	0.100 x 0.158	Bond Pad # 4	Vd1	0.110 x 0.135
Bond Pad # 2	Vg2	0.100 x 0.100	Bond Pad # 5	RF Out	0.100 x 0.158
Bond Pad # 3	Vd2 (Not used)	0.135 x 0.110	Bond Pad # 6	Vg1	0.100 x 0.100

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.



Recommended Assembly Diagram



GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.



Assembly Notes

Component placement and adhesive attachment assembly notes:

- Vacuum pencils and/or vacuum collets are the preferred method of pick up.
- · Air bridges must be avoided during placement.
- · The force impact is critical during auto placement.
- Organic attachment (i.e. epoxy) can be used in low-power applications.
- Curing should be done in a convection oven; proper exhaust is a safety concern.

Reflow process assembly notes:

- Use AuSn (80/20) solder and limit exposure to temperatures above 300°C to 3-4 minutes, maximum.
- · An alloy station or conveyor furnace with reducing atmosphere should be used.
- Do not use any kind of flux.
- · Coefficient of thermal expansion matching is critical for long-term reliability.
- · Devices must be stored in a dry nitrogen atmosphere.

Interconnect process assembly notes:

- Thermosonic ball bonding is the preferred interconnect technique.
- Force, time, and ultrasonics are critical parameters.
- Aluminum wire should not be used.
- Devices with small pad sizes should be bonded with 0.0007-inch wire.

Ordering Information

Part	ECCN	Package Style
TGA2526	EAR99	GaAs MMIC Die

GaAs MMIC devices are susceptible to damage from Electrostatic Discharge. Proper precautions should be observed during handling, assembly and test.